EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S33	20	(US-20020094686-\$ or US-20030118731-\$ or US-20040138217-\$ or US-20040138217-\$ or US-20040048841-\$ or US-20040128294-\$ or US-200401282974-\$ or US-20040026374-\$ or US-200400836-\$ or US-2004008936-\$ or US-20050215059-\$ or US-20050215059-\$ or US-20050215059-\$ or US-6613603-\$ or US-4842897-\$ or US-663603-\$ or US-4842897-\$ or US-663603-\$ or US-48737440-\$ or US-6645371-\$ or US-681101-\$ or US-6861101-\$ or US-6861101-\$ or US-6737440-\$	US PCPUB; USPAT; JPO; DEFWENT	ADJ	ON	2008/11/10
S34	389100	S33 and (silicon) or (silicon near2 \$20xide\$2)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/10 15:48
S 35	13	S33 and ((silicon) or (silicon near2 \$2oxide\$2))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/10 15:48
S36	2	("2002/0094686").URPN.	USPAT	ADJ	ON	2008/11/10 16:08
S37	1	("20060170740").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2008/11/12 08:01
S38	11695	semiconductor\$2 and (silicon with dielectric)	EPO; JPO; DERWENT	ADJ	ON	2008/11/12 08:51
S39	13	semiconductor\$2 and (silicon with dielectric) and (micro near2 (fissur\$3 or crack\$3 or trench\$3 or via \$2))	EPO; JPO; DERWENT	ADJ	ON	2008/11/12 08:54
S40	1	("1158072").PN.	EPO	OR	OFF	2008/11/12 09:08

S41	2	("6783875").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/11/12 09:14
S44	4123	semiconductor\$2 and (("si" or silicon) same ("yt" or yttrium) same oxide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/12 09:24
S45	38	semiconductor\$2 and (("si" or silicon) same ("yt" or yttrium) same oxide) same (rough\$4 with surface)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/12 09:25
S46	37	semiconductor\$2 and (("si" or silicon or "sio. sub."\$) same ("yt" or yttrium or "yto.sub."\$) same \$20xide) same (rough\$4 with surface)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/12 10:19
S47	94	semiconductor\$2 and (("si" or silicon) same ("y" or yttrium) same \$20xide) same (rough\$4 with surface)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/12 10:25
S48	95	semiconductor\$2 and (("si" or silicon) same ("y" or yttrium) same \$20xide) same ((rough\$4 with surface) or (micro near\$ (crack\$4 or fissur\$3 or trench\$2 or via\$2)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/11/12 10:26

^{11/12/2008 3:46:19} PM
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